

Carrier lifetime variations during irradiation by 3 - 8 MeV protons @ 40-300 K in MCZ Si

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Outline

- HUAL & VU instrumentation for lifetime measurement during proton irradiation, in-situ positioning and control
- Lifetime-temperature characteristics for initial MCz material and during irradiation with stopped and penetrative protons at different temperatures
- Summary

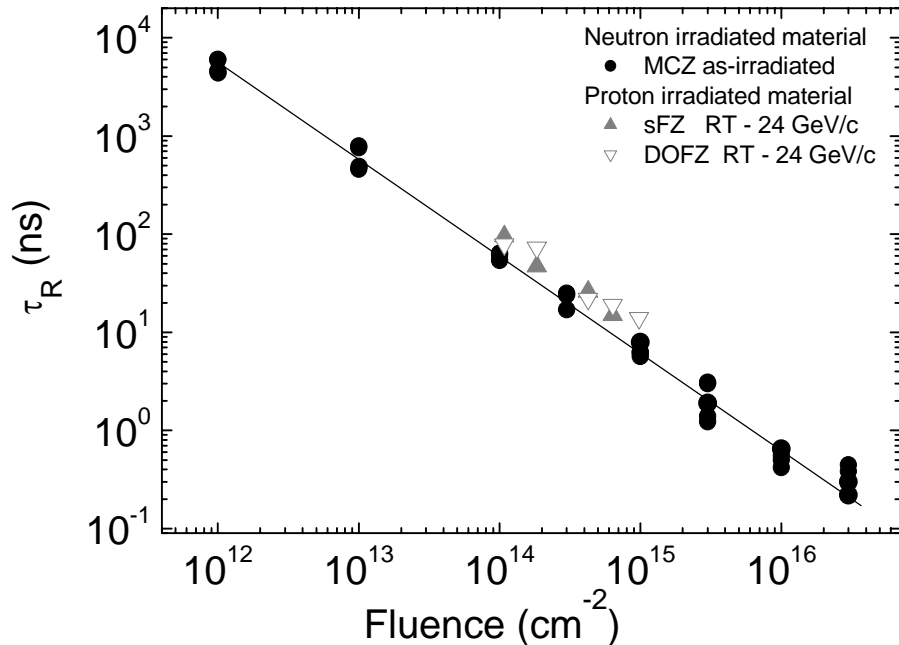
Motivavtion

It is interesting to understand:

if this linear dependence is
a result of irradiation

or

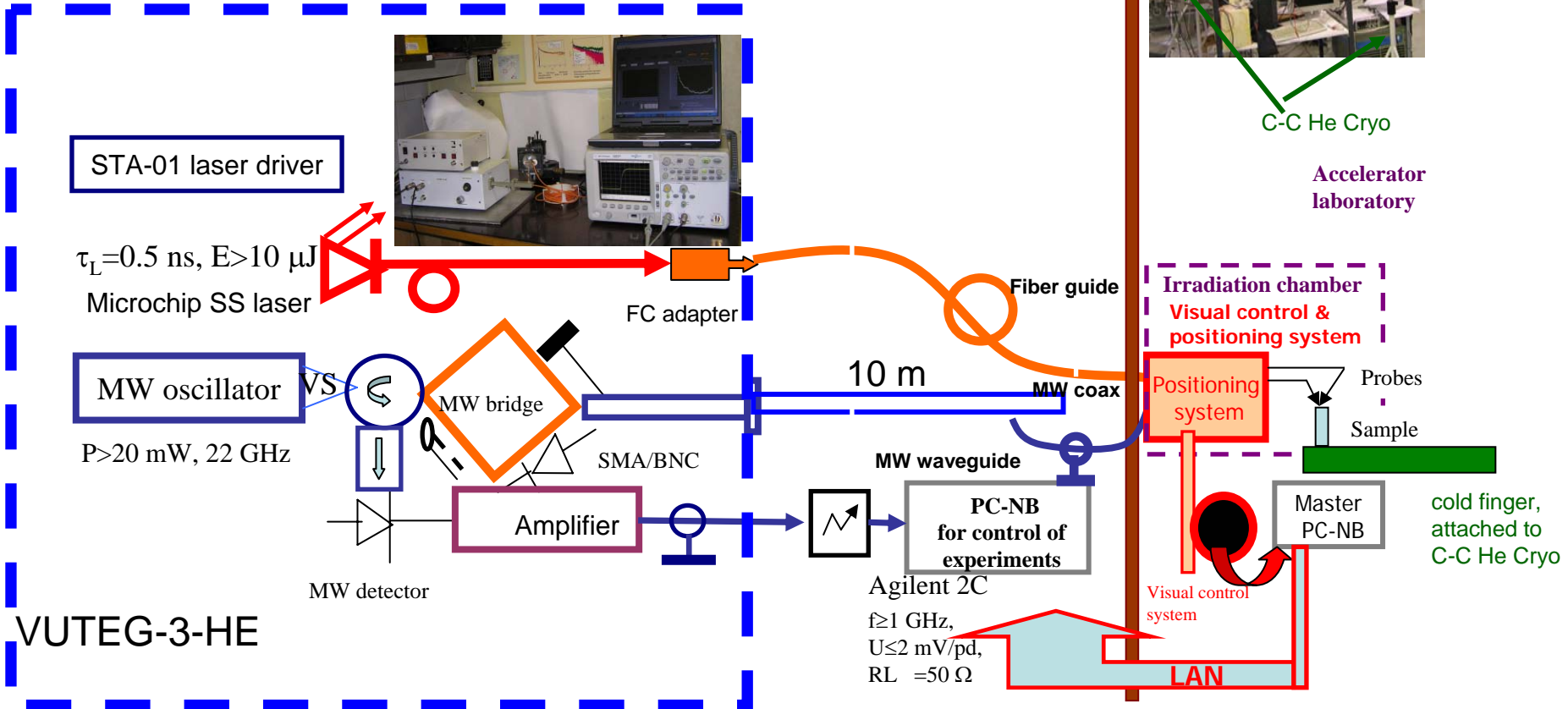
it is a consequence of
irradiation and migration
of defects to form other
type of defects



The dependence of the lifetime on the fluence in the neutron and proton irradiated Si.

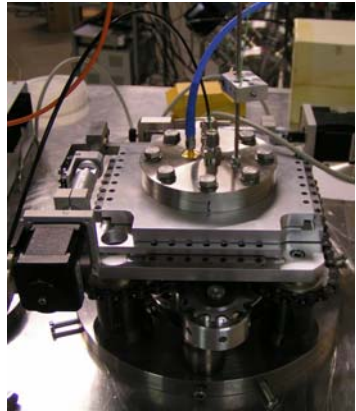
Scheme of the installed instrumentation

Modules outside irradiation area

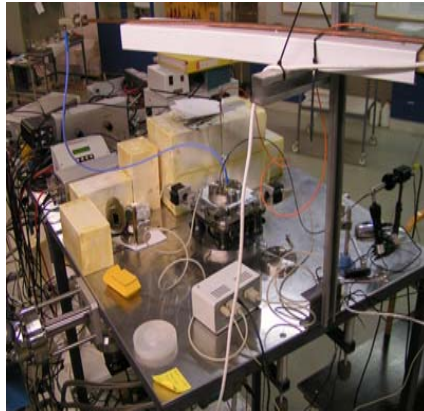


The microwave probed photoconductivity (MW-PC) modules for the direct measurements of the carrier decay transients by employing MW absorption are assembled. VUTEG-3HE, master PC-NB, antenna/excitation fiber modules, positioning and visual control modules are installed within irradiation chamber containing a cold finger for cooling of a sample by using closed-cycle He cryostat. Delivering of signals to destination outside running irradiation area are implemented by using LAN.

Assembled instrumentation for τ -exposure-T measurements



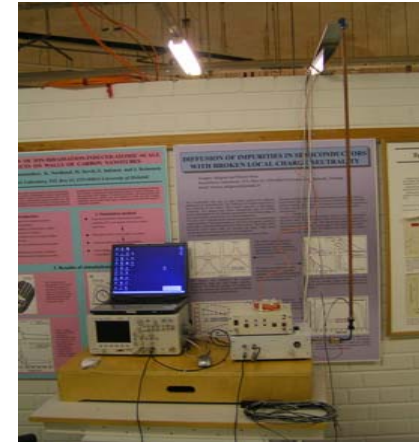
3D positioning & inputs



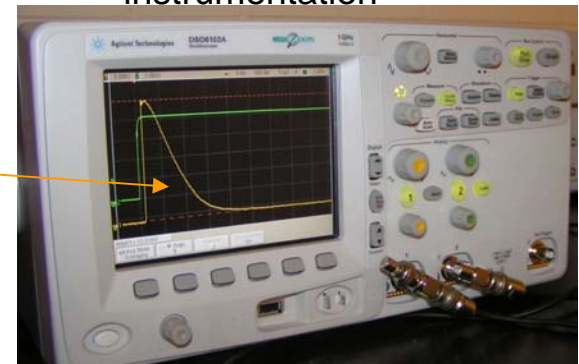
Drivers & and remote control instrumentation



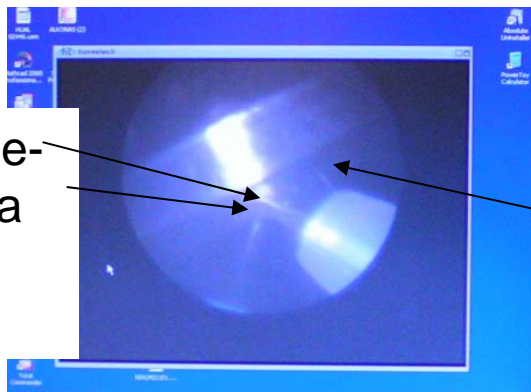
Distant transfer lines



Beyond-radiation area & Measurement and operating instrumentation



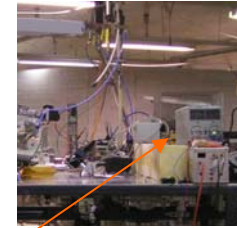
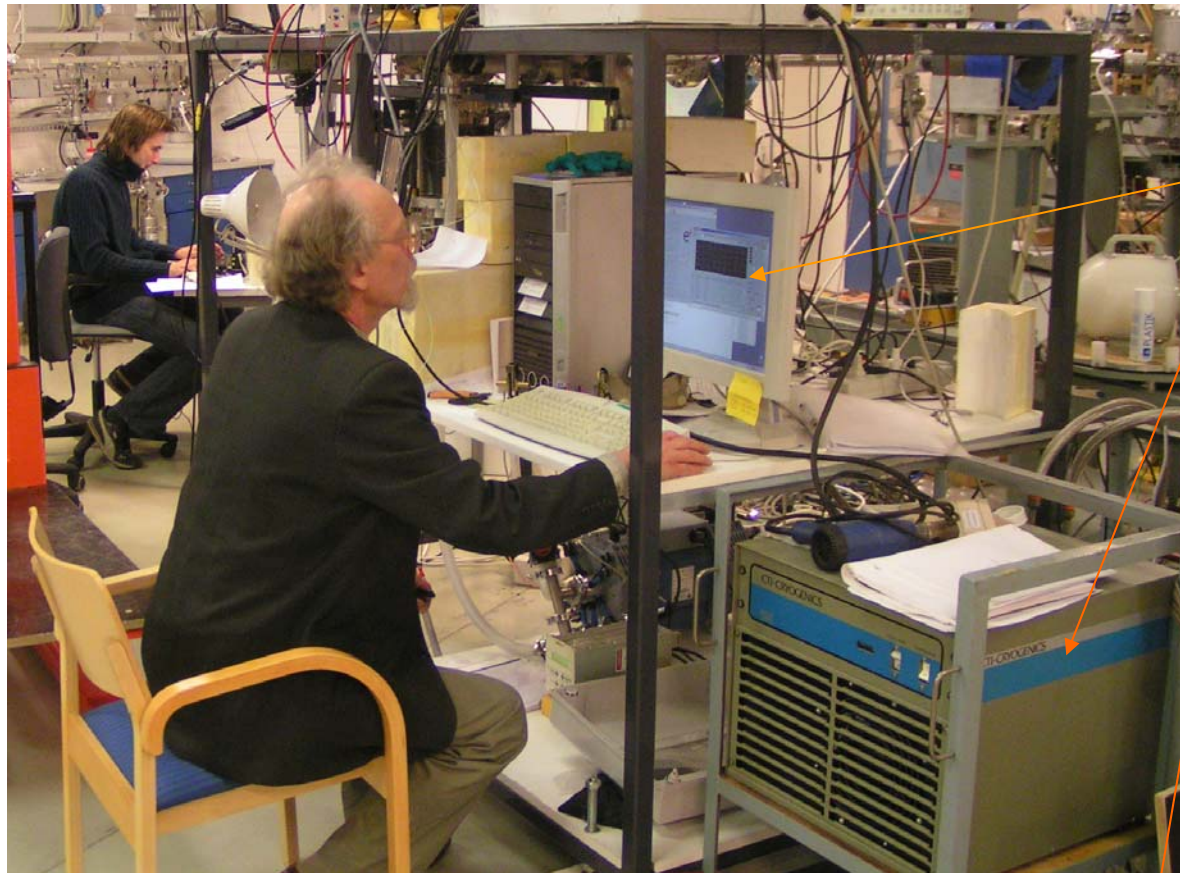
MW-PC signal



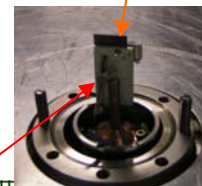
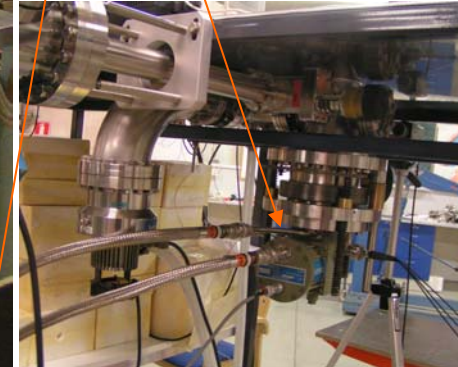
MW needle-tip antenna and fiber probes

Sample side for cross-sectional scan

τ -T measurements after irradiations

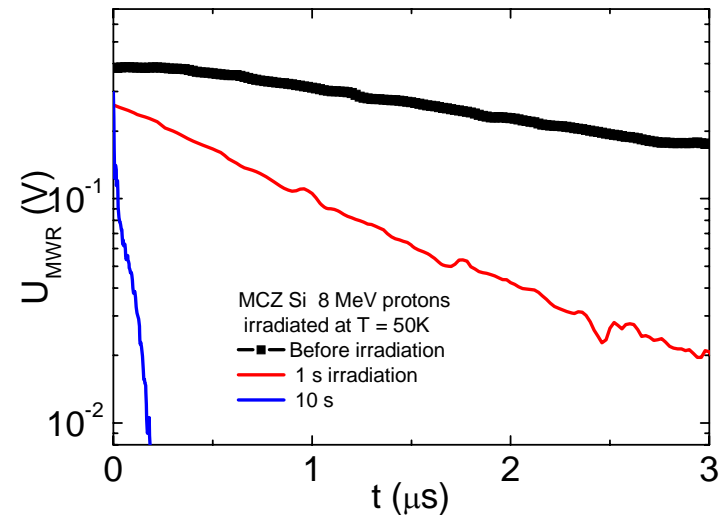
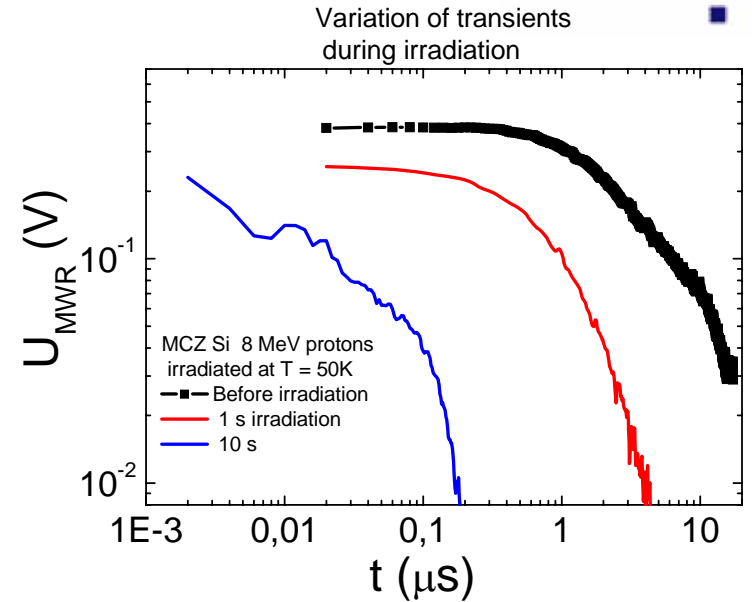
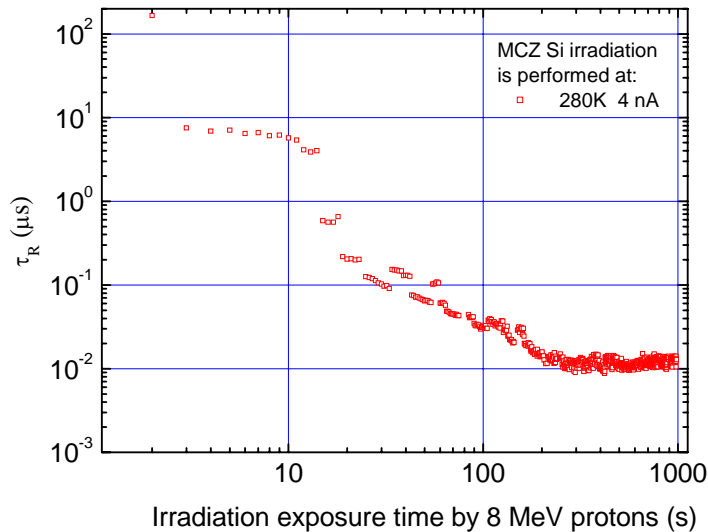
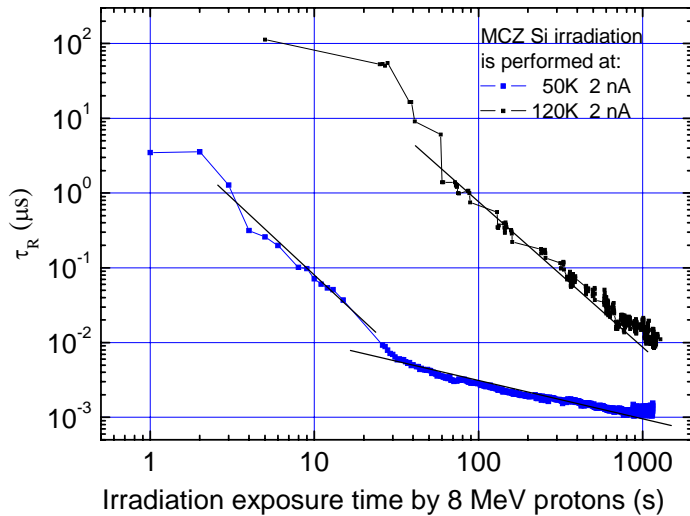


HUAL in-chamber
temperature
control system

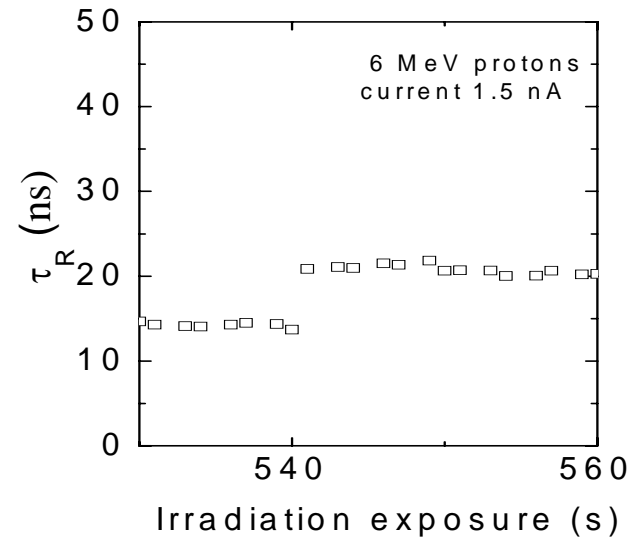
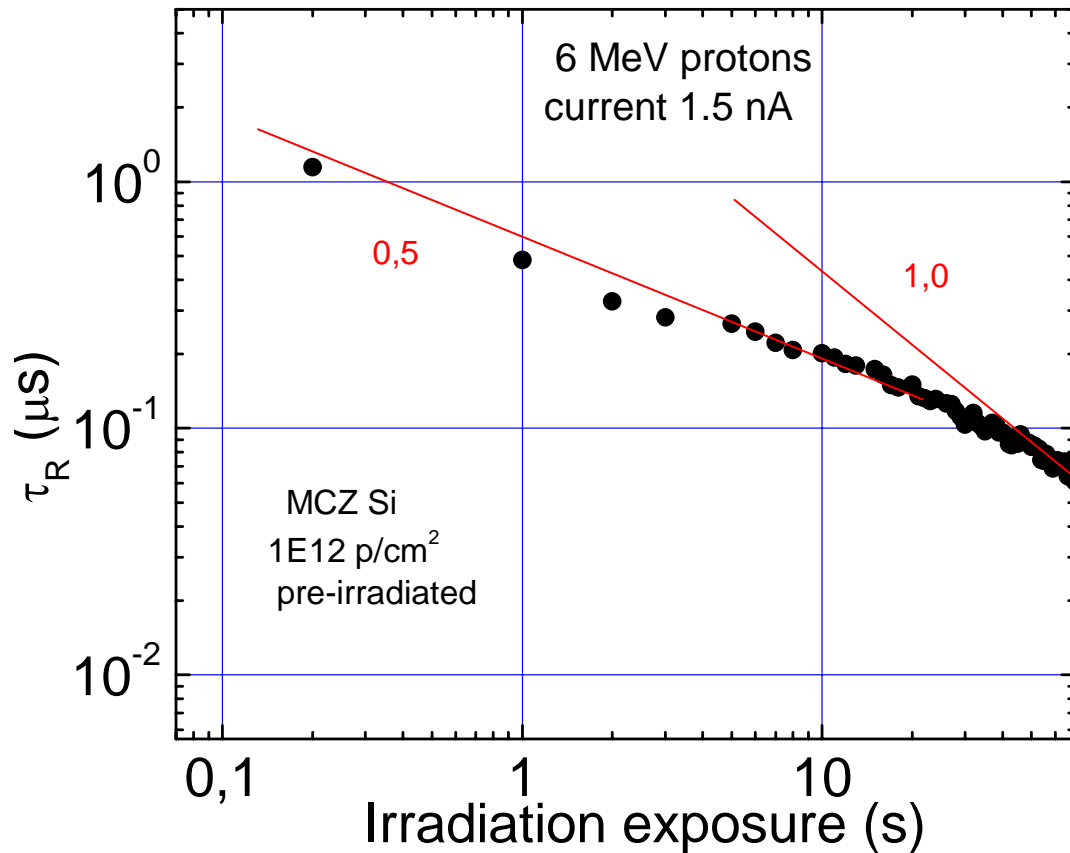


Thermo-couple

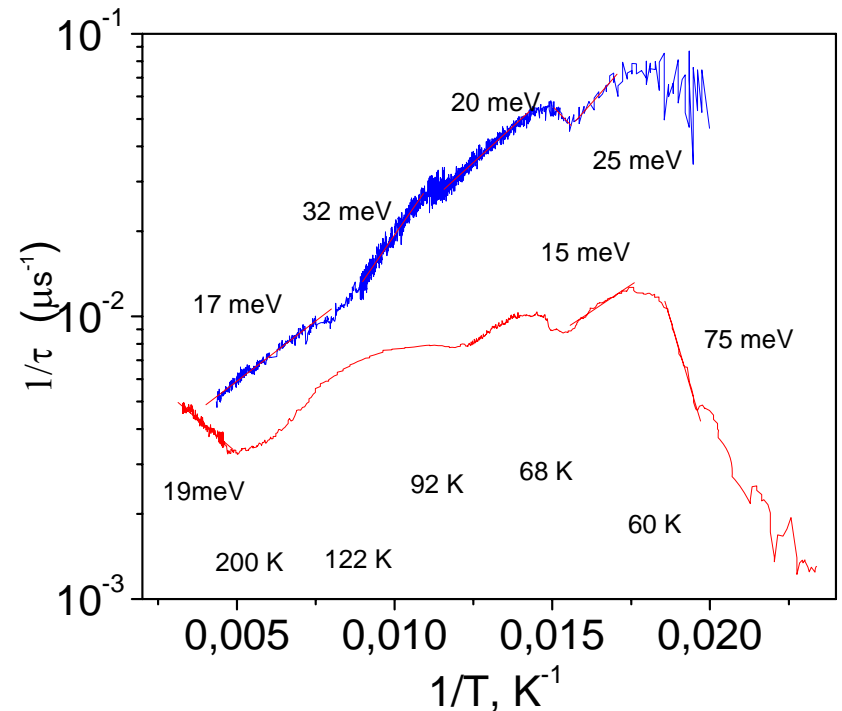
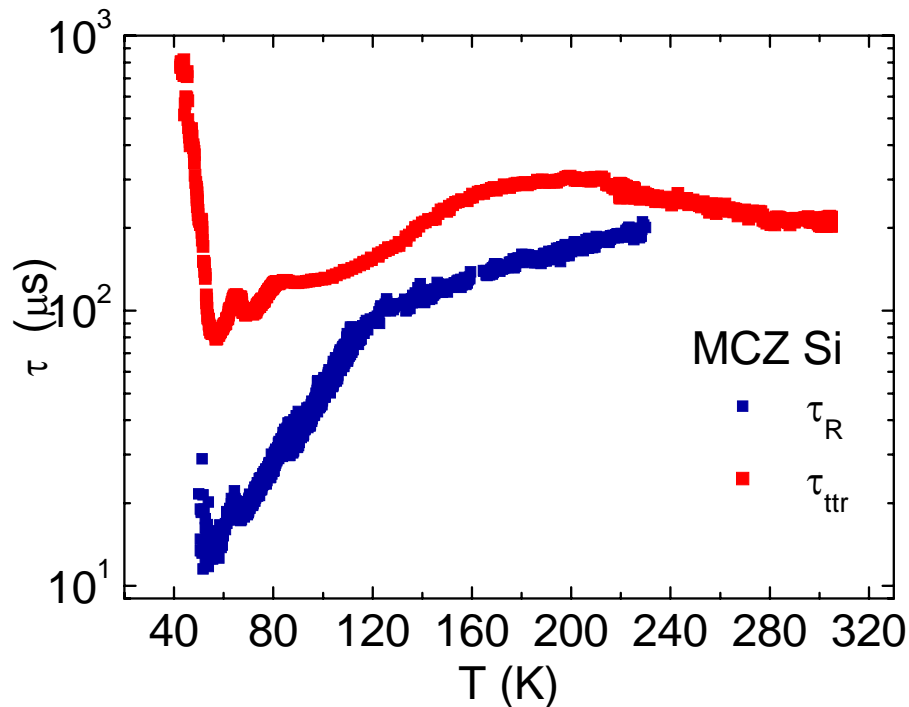
τ -exposure at various T characteristics during irradiation with penetrative protons probes are located at half-width of wafer thickness



Irradiation of pre-irradiated Si



τ -T results for initial material before irradiation



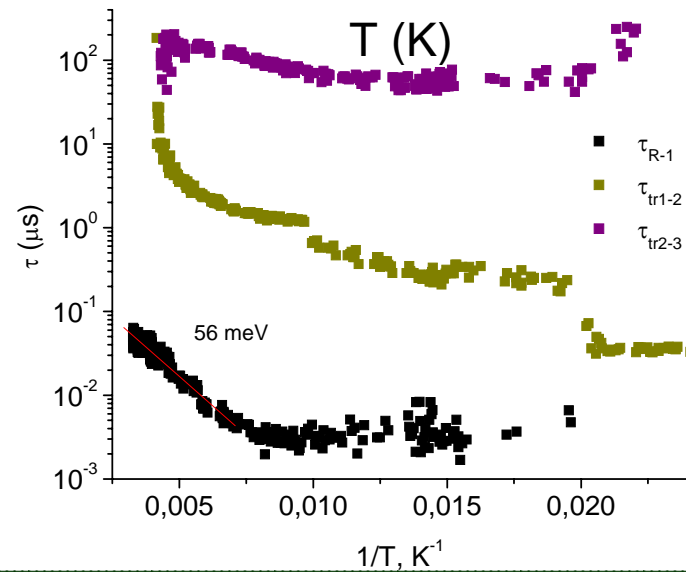
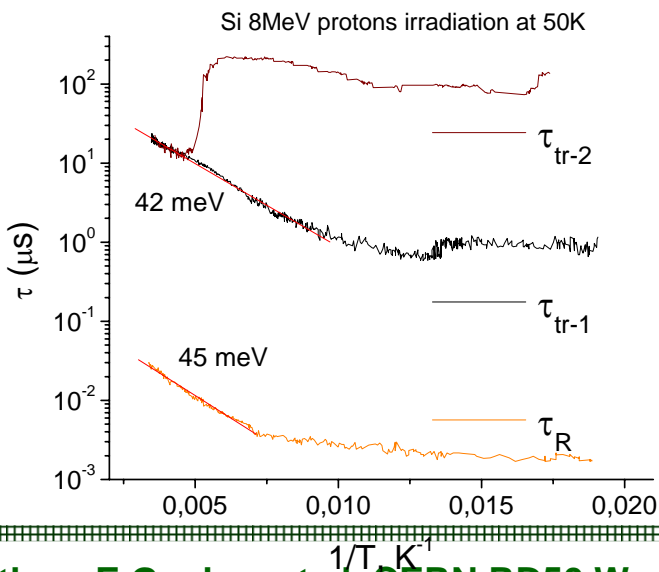
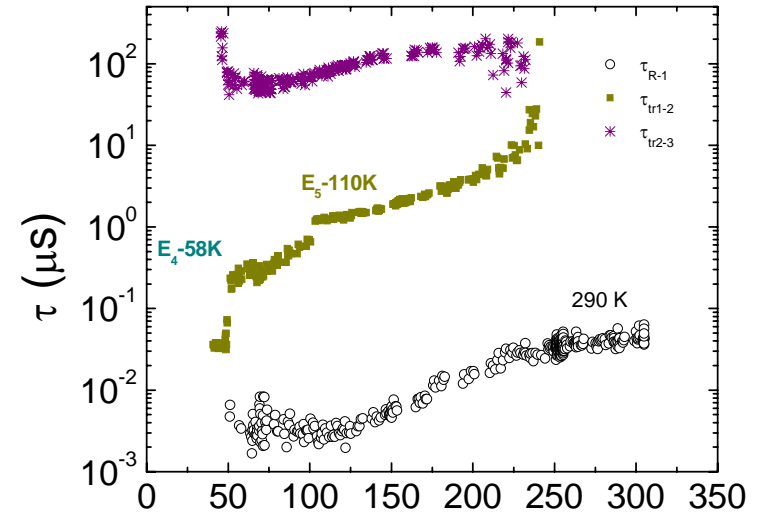
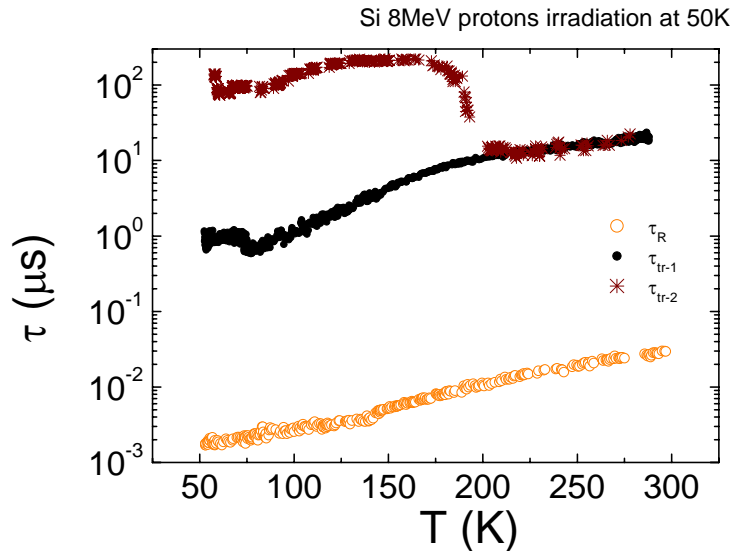
Two-componential decay in the initial MCZ material wafers, ascribed to carrier recombination (τ_R) and trapping (τ_{ttr}), is observed, and these decay constituents show different temperature characteristics.

For trapping constituent, a few peaks was be observed.

τ -T characteristics in the 8 MeV proton post-irradiated material

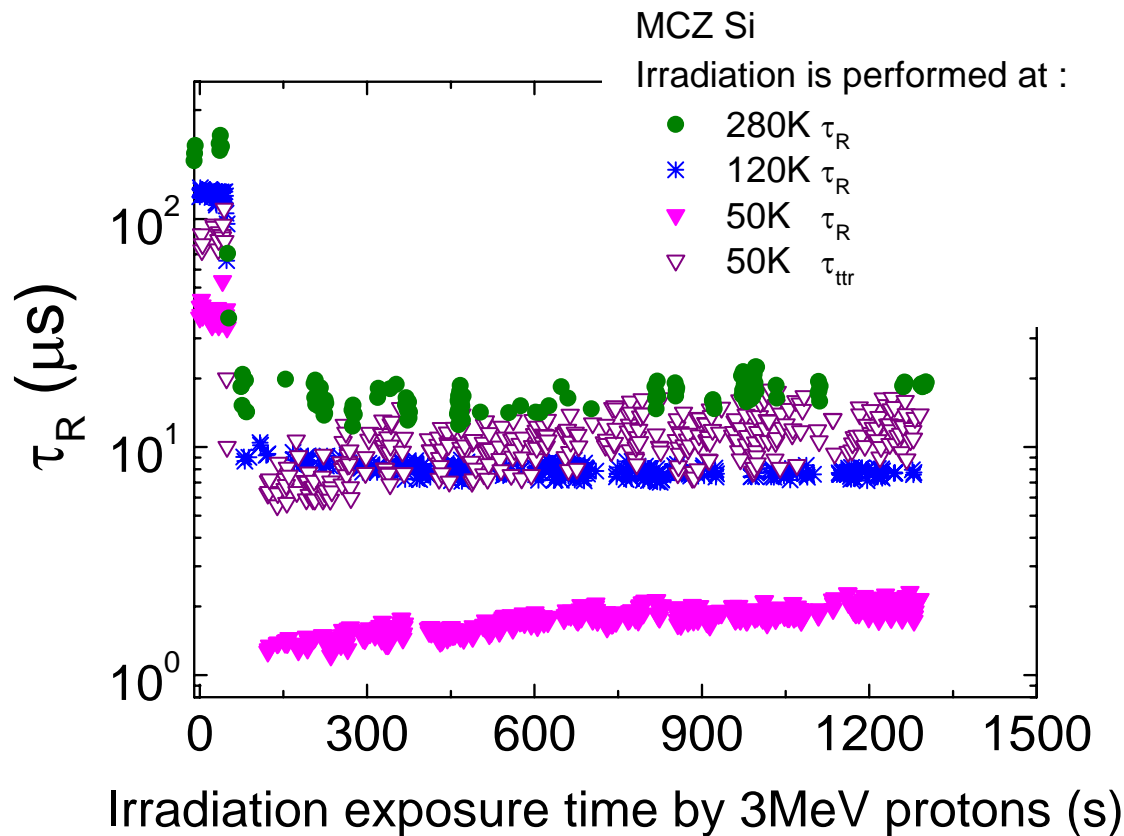
Several carrier trapping components appear in τ -T characteristics after irradiation.

Si 8MeV protons irradiated at T= 280K



τ -exposure dependence during implantation of 3 MeV protons

Microwave probe and optical fiber are located at $\sim 80 \mu\text{m}$ distance from the irradiation (beam side) face-surface of wafer



Summary

- The dependence of lifetime on fluence during irradiation by protons shows a dependence of defects generation rate on the temperature and of irradiation, i.e., irradiation itself induces the defect reactions in the sample.
- The pre-irradiation also creates the different conditions for defect reactions.

(The increase of statistics is necessary)

- Two-componential decay in the initial MCZ material wafers, ascribed to carrier recombination (τ_R) and trapping (τ_{ttr}), is observed, and these decay constituents show different temperature characteristics.
- Several carrier trapping components appear in τ -T characteristics after irradiation by penetrative protons.

Thank You for attention!

and

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